		Type	L	#	Hits	Search Text	DBs	Time Stamp
		BRS	L1		2	(dual adj3 purpose) same (electrochemical\$3) same (oxide or oxides) same (conductive)	USPAT US-PG UB; EPO; JPO; DERWEI T; IBM_TI	2002/10/01 N 14:59
2	E	BRS	L2		549	(electrochemical\$3) same (reduc\$3) same (oxide\$3) same (conduct\$7)	USPAT, US-PGI UB; EPO; JPO; DERWEN T; IBM_TI B	2002/10/01 15:05
3	E	BRS	L3		62	2 and (interconnect or interconnects)	USPAT; US-PGF UB; EPO; JPO; DERWEN T; IBM_TD	2002/10/01 15:06
4	В	RS	L4	-	11908	(dual adj3 (purpose or purposes))	USPAT	2002/10/01 16:11
5	В	RS	L5		3	4 same (electrochemically)	USPAT	2002/10/01 16:12
6	В	RS	L7	4	1 4	(electro adj3 chemical\$3) same reduc\$3 same oxide\$3	USPAT	2002/10/01 16:16
7	В	RS	L10	1	L 9	7 and copper	USPAT	2002/10/01 16:17
8	B	RS	L11	6	52	(dual adj3 purpose) adj3 (layer or layers or film or films)	USPAT	2002/10/01 16:25
9	Bl	RS :	L12	g)	11 and (tungsten)	USPAT	2002/10/01 16:25
10	ВІ	RS]	L13	2	1	(dual adj3 purpose) same tungsten	USPAT	2002/10/01 16:30
11	В	RS]	և14	5		13 and (interconnect or interconnects)	USPAI :	2002/10/01 16:57
12	BF	RS I	L15	0	1	dual same tungsten same (interconnect or interconnects) same (electrochèmical\$3)	ПСФДТ	2002/10/01 16:58

		Туре	L #	Hits	Search Text	DBs	Time Stamp
1	3_	IS&R	L17	1	("6261954").PN.	USPAT	2002/10/01 17:35
1	4	BRS	L18	20	16 and (electrochemical\$3)	USPAT	2002/10/01 17:40
1	5	BRS	L19	154	dual same tungsten same (interconnect or interconnects)	USPAT	2002/10/01 17:40
1	6	BRS	L20	154	dual same tungsten same (interconnect or interconnects)	USPAT	2002/10/01 17:41
1	7	BRS	L21	5	20 and (electrochemically)	USPAT, US-PGH UB; EPO; JPO; DERWEN T; IBM_TI	2002/10/01 17:42
18	3 1	BRS	L22	519	(electrochemically) same (reduce or reduced or reducing) same (oxide or oxides)	USPAT; US-PGF UB; EPO; JPO; DERWEN T; IBM_TD B	2002/10/01 17:47
19	E	BRS	L23	232	22 and (tungsten or W)		2002/10/01 17:47
20	В	RS]	L24	37	22 same (tungsten or W)	· · · · ·	2002/10/01 17:50

		Туре	L #	Hits	Search Text	DBs	Time Stamp
2	1	BRS	L25	10	24 same (surface or surfaces)	USPAT US-PG UB; EPO; JPO; DERWE: T; IBM_T: B	2002/10/01 N 17:55
2:	2]	BRS	L26	3	(electrochemical\$10) same (reduce or reduced or reducing) same (oxide or oxides) same (surface or surfaces) same dual	USPAT US-PGI UB; EPO; JPO; DERWEN T; IBM_TI	2002/10/01 17:57
23	3 E	BRS	L27		(electrochemical\$10) same (reduce or reduced or reducing) same (oxide or oxides) same (surface or surfaces)	USPAT; US-PGF UB; EPO; JPO; DERWEN T; IBM_TD B	2002/10/01 18:06
24	В	RS]	L28	0	(surface or surfaces) adj10 (surface or surfaces) adj10 (tungsten or W)	USPAT; US-PGP UB; EPO; JPO; DERWEN T; IBM_TD B	2002/10/01 18:07
25	BI	RS L	.29	252 (electrochem\$10) adj10 oxide or oxides) adj10 surface or surfaces)	O O /	2002/10/01 18:07

		Type	L	# Hit	s Search Text	DBs	Time Stamp
2	6	BRS	L30	O	29 and (barrier adj10 tungsten)	USPAT US-PG UB; EPO; JPO; DERWEI T; IBM_TI B	2002/10/01 18:08
2*	7 1	3RS	L31	3 6	29 and tungsten	USPAT; US-PGE UB; EPO; JPO; DERWEN T; IBM_TD	2002/10/01 18:08
28	ВВ	RS	L32	467	electrochemically or electrochemical) same reducing	USPAT; US-PGP UB; EPO; JPO; DERWEN T; IBM_TD B	2002/10/01 18:14
29	Ві	RS .	L33	1	32 and ((barrier adj10 (tungsten or W)))	USPAT; US-PGP UB; EPO; JPO; DERWEN T; IBM_TD B	2002/10/01
30	BR	RS I	J34	153	32 and (tungsten or W)	DERWEN ¹ f; [BM_TD	2002/10/01

	Туре	L #	# Hits	Search Text	DBs	Time Stamp
1	BRS	L1	2	(dual adj3 purpose) same (electrochemical\$3) same (oxide or oxides) same (conductive)	USPAT, US-PGH UB; EPO; JPO; DERWEN T; IBM_TH	2002/10/01 14:59
2	BRS	L2	549	(electrochemical\$3) same (reduc\$3) same (oxide\$3) same (conduct\$7)	USPAT; US-PGF UB; EPO; JPO; DERWEN T; IBM_TD	2002/10/01 15:05
3	BRS	L3	62	2 and (interconnect or interconnects)	USPAT; US-PGP UB; EPO; JPO; DERWEN T; IBM_TD B	2002/10/01 15:06
4	BRS	L4	11908	(dual adj3 (purpose or purposes))		2002/10/01 16:11
5	BRS	L5	3	4 same (electrochemically)	:U.O.F.A.I. ;	2002/10/01 16:12
6	BRS	L7	44	(electro adj3 chemical\$3) same reduc\$3 same oxide\$3		2002/10/01 16:16
7	BRS	L10	19	7 and copper	! ()) F M	2002/10/01 16:17

-		Туре	L	#	Hits	Search Text	7 22-	T
-		-21				Search Text	DBs	Time Stamp
1		BRS	L1		2	(dual adj3 purpose) same (electrochemical\$3) same (oxide or oxides) same (conductive)	USPAT US-PGI UB; EPO; JPO; DERWEN T; IBM_TI	2002/10/01 14:59
2	E	BRS	L2		549	(electrochemical\$3) same (reduc\$3) same (oxide\$3) same (conduct\$7)	USPAT; US-PGF UB; EPO; JPO; DERWEN T; IBM_TD	2002/10/01 15:05
3	В	BRS	L3			2 and (interconnect or interconnects)	USPAT; US-PGP UB; EPO; JPO; DERWEN T; IBM_TD B	2002/10/01 15:06
4	В	RS :	L4	1		(dual adj3 (purpose or purposes))	USPAT	2002/10/01 16:11
5	В	RS :	L5	3		<u> </u>	USPAT	2002/10/01 16:12
6	В	RS]	L7	4	4	(electro adj3 chemical\$3) same reduc\$3 same oxide\$3	USPAT	2002/10/01 16:16
7	В	RS 1	L10	1	i	7 and copper	ILISPAI :	2002/10/01 16:17
8	BI	RS I	L11	6	2	(dual adj3 purpose) adj3 (layer or layers or film or films)	דעפטוו	2002/10/01 16:25
9	ВІ	RS I	12	9	1	1 and (tungsten)		2002/10/01 16:25

		Туре	L	#	Hits	Search Text	DBs	Time Stamp
1		BRS	L1		2	(dual adj3 purpose) same (electrochemical\$3) same (oxide or oxides) same (conductive)	USPAT US-PG UB; EPO; JPO; DERWEI T; IBM_TI	2002/10/01 N 14:59
2	I	BRS	L2		549	(electrochemical\$3) same (reduc\$3) same (oxide\$3) same (conduct\$7)	USPAT, US-PGI UB; EPO; JPO; DERWEN T; IBM_TI B	2002/10/01 15:05
3	E	BRS	L3		62	2 and (interconnect or interconnects)	USPAT; US-PGF UB; EPO; JPO; DERWEN T; IBM_TD	2002/10/01 15:06
4	В	BRS	L4	j	L1908	(dual adj3 (purpose or purposes))	USPAT	2002/10/01 16:11
5	В	RS	L5		3	4 same (electrochemically)	USPAT	2002/10/01 16:12
6	В	RS :	L7	4	14	(electro adj3 chemical\$3) same reduc\$3 same oxide\$3	USPAT	2002/10/01 16:16
7	В	RS]	L10	1	. 9	7 and copper	USPAT	2002/10/01 16:17
8	B.	RS I	L11	6	52	(dual adj3 purpose) adj3 (layer or layers or film or films)	USPAT	2002/10/01 16:25
9	В	RS I	L12	9		11 and (tungsten)	USPAT	2002/10/01 16:25
10	ВІ	RS I	L13	2	1	(dual adj3 purpose) same tungsten	USPAT	2002/10/01 16:30
11	ВІ	RS I	L14	5	•••••••	13 and (interconnect or interconnects)	IISPAT	2002/10/01 16:57
12	ВІ	RS I	15	0		dual same tungsten same (interconnect or	ПСБУП	2002/10/01

		Туре	L #	Hits	Search Text	DBs	Time Stamp
1	3_	IS&R	L17	1	("6261954").PN.	USPAT	2002/10/01 17:35
1	4	BRS	L18	20	16 and (electrochemical\$3)	USPAT	2002/10/01 17:40
1	5	BRS	L19	154	dual same tungsten same (interconnect or interconnects)	USPAT	2002/10/01 17:40
1	6	BRS	L20	154	dual same tungsten same (interconnect or interconnects)	USPAT	2002/10/01 17:41
1	7	BRS	L21	5	20 and (electrochemically)	USPAT; US-PGE UB; EPO; JPO; DERWEN T; IBM_TE	2002/10/01 17:42
18	3]	BRS	L22	519	(electrochemically) same (reduce or reduced or reducing) same (oxide or oxides)	USPAT; US-PGP UB; EPO; JPO; DERWEN T; IBM_TD B	2002/10/01 17:47
19	E	BRS	L23	232	22 and (tungsten or W)	USPAT; US-PGP UB; EPO; JPO; DERWEN T; IBM_TD B	2002/10/01
20	В	BRS]	L24 (37 2	22 same (tungsten or W)		2002/10/01 17:50

	Туре	L #	Hits	Search Text	DBs	Time Stamp
21	. BRS	L25	10	24 same (surface or surfaces)	USPAT US-PG UB; EPO; JPO; DERWEI T; IBM_TI	2002/10/01 N 17:55
22	BRS	L26	3	(electrochemical\$10) same (reduce or reduced or reducing) same (oxide or oxides) same (surface or surfaces) same dual	USPAT; US-PGE UB; EPO; JPO; DERWEN T; IBM_TD	2002/10/01 117:57
23	BRS	L27	624		USPAT; US-PGP UB; EPO; JPO; DERWEN T; IBM_TD B	2002/10/01 18:06
24	BRS	L28	0	(electrochem\$10) adj10 (oxide or oxides) adj10 (surface or surfaces) adj10 (tungsten or W)	 ;	2002/10/01 18:07
25	BRS	L29	252 (electrochem\$10) adj10 oxide or oxides) adj10 surface or surfaces)	DERWEN : I; IBM_TD	2002/10/01 18:07

		Туре	L#	Hits	Search Text	DBs	Time Stamp
2	26	BRS	L30	0	cungscen	USPAT; US-PGP UB; EPO; JPO; DERWEN T; IBM_TD B	2002/10/01 18:08
2	7	BRS	L31	36	29 and tungsten	USPAT; US-PGP UB; EPO; JPO; DERWEN T; IBM_TD B	2002/10/01 18:08

	Туре	Hits	Search Text
1	BRS	41	(dual adj3 purpose) adj3 layer
2	BRS	5	((dual adj3 purpose) adj3 layer) and (electrochemical or electrochemically)
3	BRS	1`	((dual adj3 purpose) adj3 layer) same (tungsten or (tungsten adj nitride) or (tungsten adj3 silicon adj3 nitride))

	DBs	Time Stamp			
	USPAT; US-PGPUB;				
1	EPO; JPO; DERWENT; IBM_TDB	2002/10/01 11:43			
	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/10/01 11:43			
	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/10/01 11:46			

	Type	L #	Hits	Search Text	DBs	Time Stamp
1	BRS	L1	2	:	USPAT; US-PGP UB; EPO; JPO; DERWEN T; IBM_TD B	2002/10/01
2	BRS	L2	549	(electrochemical\$3) same (reduc\$3) same (oxide\$3) same (conduct\$7)	USPAT; US-PGP UB; EPO; JPO; DERWEN T; IBM_TD B	2002/10/01 15:05
 3	BRS	L3		2 and (interconnect or interconnects)	USPAT; US-PGP UB; EPO; JPO; DERWEN T; IBM_TD B	2002/10/01